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A New Reduction Mechanism of CO Dimer by Hydrogenation into C₂H₄ on Cu(100) Surface: A Theoretical Insight into Kinetics of Elementary Steps

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Abstract A systematic DFT study that examines the role of kinetics of elementary reaction steps during the course of reduction of CO dimer, OCCO* into production C₂H₄ on Cu(100) is presented for the first time in the present work, and a new mechanism is introduced. The kinetic analysis of elementary reaction steps have suggested that further reduction of CO is key selectivity-determining step for the formation of C₂H₄ and CH₄ on Cu(100) and Cu(111). The main reaction pathway on Cu(111) proceeds through reduction of CO into CHO* intermediate, which may eventually result in CH_x species by the breaking of C-O bond, and produce production CH₄. On Cu(100), OCCO* is firstly formed by CO dimerization, which is the first step and more favorable pathway than the further hydrogenation of CO. It explains why only C₂ species and not C₁ species are observed experimentally on Cu(100). For the formation of production C₂H₄ on Cu(100), the results suggest that hydrogenation of OCCO* to OCCHO* intermediate is the most possible reaction path, followed by the formation of intermediate OHCCHO* through OCCHO* intermediate further hydrogenation. The formation of OCCO* may be rate-determining step in reduction mechanism of CO dimer. Our present reaction kinetics analysis of elementary steps give a different mechanistic explanation for selectivity of production C₂H₄ in contrast to previous suggested thermodynamic theoretical study on the reduction mechanisms of CO dimer into C₂H₄. This present reduction pathway is consistent with the latest experimental results and explains the puzzle in experiment on uncertainty of reaction intermediates. At present, it seems to us that the mechanism that proposed in this work is most agreeable with the present experimental results.

Keywords CO Dimerization; C₂H₄; Cu(100); Reduction Mechanism; Kinetics

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1. Introduction

Reducing carbon dioxide (CO₂) into carbon-neutral fuel and renewable feedstock of carbon-based fine chemicals would positively impact the global carbon balance and offer a novel solution to the dilemma of growing energy demand and global warming we are facing nowadays.^{1,2} In this area, a landmark discovery was made in 1985 by Hori, who found that CO₂ can be reduced to ethylene (C₂H₄) and methane (CH₄) on Cu electrodes,3 and the extent of C2H4 and CH4 formation sensitively depends on the surface orientation of the Cu electrode. On the (100) facet of Cu fcc crystal, the formation of C₂H₄ is dominant, whereas on the (111) facet, the formation of CH₄ is favored. However, an overpotential of almost 1 V on Cu electrodes is required, which hinder global spread of this technology. Thus, the study of reduction mechanism of CO₂ is extremely urgent on Cu electrode. At present, most of the studies devoted to understanding its reduction mechanism on Cu electrodes have been experimental, 5-10 while theoretical insight has been provided recently for the formation of C₁ species, such as CH₄. ¹¹⁻¹⁶ In spite of extensive literature, the molecular-level details of the mechanism of the CO₂ reduction on Cu electrodes is still not clearly understood, in particular in relation to the C-C coupling step leading to the formation of C₂H₄ on Cu(100). However, all of these studies showed that CO appears to be an important intermediate during the course of reduction. Electroreduction of CO leads to a similar product distribution as observed for CO₂ reduction, ¹⁷ producing both C₂H₄ and CH₄ through different reduction pathways. Similar hydrocarbon products yielded in experiments on CO electroreduction on Cu electrodes have established that adsorbed CO is a key intermediate in the formation of both C₂H₄ and CH₄. 17-19 Thus, the study of CO reduction mechanisms on copper electrodes will lead to a deeper understanding of the reaction chemistry and can eventually lead to the design of more efficient and selective catalysts, which can explain the observed product distribution and the effect of different electrode facets on catalytic activity and selectivity of reaction.

Recent experimental and theoretical studies to focus on the CO reduction mechanism have mostly showed that adsorbed CHO* is a key reaction intermediate and the hydrogenative reduction of CO to an adsorbed CHO* as the rate-determining step (rds), eventually resulting in the formation of CH₄ by successive hydrogenation of cleavage of the C-O bond on Cu electrodes. However, the exact reduction mechanism of CO into C₂H₄ is still debated. The studies by Schouten and coworkers have suggested that a mechanism may exist whose rds does not depend on a proton-coupled electron transfer from an experimental standpoint since they found that yields of C₂ species are pH dependent on an RHE scale in experiment. In order to explain this phenomenon, a CO dimerization mechanism in both CO₂ and CO electroeduction is proposed on Cu(100) by Schouten and coworkers, and the electroreduction of various potential intermediates to

hydrocarbons suggests that the dimerization of CO is the rate-determining step in C2 species formation, followed by either the formation of an enediol-like species or an oxalometallocycle.8 Further work by Schouten and coworkers demonstrates a shift in the onset of C₂ formation to potentials around -0.4 V vs. reversible hydrogen electrode (RHE), providing further evidence that CO dimerization may occur. Li et al. and Kas et al. also suggest a C-C coupling mechanism based on the yields of C₂H₄ on oxide-derived Cu electrodes at potentials less negative than -0.5 V vs RHE. 20, 21 Previous theoretical studies performed by Montoya and coworkers have shown that kinetic barriers to the formation of a C-C bond between unprotonated CO adsorbates on Cu(211) surfaces are too high at a vacuum-metal interface for the turnover of production C₂ species at reasonable rates, the qualitative trends would not be changed even in the presence of applied electric fields likely to exist in electrochemical environments, 22 suggesting that CO* dimerization is kinetically unfavorable on Cu(211), and therefore of CO* to form CHO* intermediate must be proceeded before favorable kinetics can be achieved in the formation of C₂H₄. Calle-Vallejo and coworkers²³ showed that concerted proton-electron transfer, there is no impact of pH value on the formation of production C₂H₄ on Cu(100), suggesting that the rds happens at an early stage of the mechanism and that there should be no proton transfer involved in that step or in the one before it from the theoretical standpoint. Thus, it can be concluded that C-C coupling should happen before the first proton transfer for the lowest-overpotential reduction pathways. Simultaneously, their studies also suggested that activation energies to CO dimerization with an Eley-Rideal mechanism (i.e., only one of the CO molecules adsorbs on the surface and the other one from the gas phase reacts with the adsorbed CO molecule directly, without adsorbing), are not as high on Cu(100) compared with that with an Langmuir-Hinshelwood mechanism, i.e., two CO molecules adsorb at neighboring sites on Cu(111). However, the exergonic binding energy of CO on (211) steps and (100) terraces of Cu¹⁵ suggest that adsorbed, rather than gas-phase CO is the relevant precursor to the kinetics of C-C coupling between two CO molecules. Additionally, this previous work from Calle-Vallejo and coworkers also proposed a stabilization of the CO dimer and its transition state by scaling the energy using the number of excess electrons in the adsorbed species as determined from a Bader charge analysis. Most recently, Montoya and coworkers presented DFT simulations for CO dimerization mechanism and demonstrated that CO dimerization should have a lower activation barrier on Cu(100) than Cu(111),²⁴ suggesting that Cu(100) surface has a high activity for C-C coupling. However, the theoretical study conducted by Montoya and coworkers only considered C-C coupling mechanism of Cu(211) surface,²² whereas Cu(100) facet has been reported to be particularly selective towards C₂H₄ production. C₂ products can be formed at low overpotentials without the formation of C₁ products on Cu(100).^{3,4,8,9,17-19} Although

they also considered CO dimer as the intermediate during the course of the formation of C_2H_4 , no detailed DFT-based mechanism for the formation of C_2H_4 was suggested on Cu(100).²⁴ In the theoretical study on Cu(100) from Calle-Vallejo and coworkers, the used model is purely thermodynamically and assumes that the kinetic barriers of uphill processes are not much larger than their reaction energies and those downhill processes have easily surmountable barriers.²³ In spite of extensive experimental and theoretical studies, it is still unknown whether adsorbed CO or a more reduced C_1 species is coupled to make C_2H_4 production, thus leaving the main reaction path, reaction intermediates and selectivity-determining and rate-determining steps for C_2H_4 production on Cu(100) electrocatalysts still uncertain. Understanding the C-C bonding formation is important, as it would aid in the design of new catalysts that are active at a lower overpotential and open up routes to the production of high-energy fuels by the electrochemical reduction of CO_2 .

In the present work, we carry out a systematic DFT study of reduction mechanism of CO dimer to form production C_2H_4 in CO_2 electroreduction on Cu(100) electrode, for the first time examining the kinetic energy of various possible elementary reaction steps during the course of reduction of CO dimer to form production C_2H_4 , and determining the selectivity-determining and rate-determining steps. As electrocatalytic reactions on catalysts that include electrolyte environment are far too complex for a complete theoretical description into kinetics of elementary steps, the complexity is first reduced. Consequently, in the present study, we restrict our calculations to close packed surfaces and periodic gas-phase environment. However, the theoretical evidence of reduction mechanism of CO dimer of Cu(100) surface is still able to be presented qualitatively in this work. The results will explain the experimental observations and provide theoretical support for the reduction mechanism of CO dimer previously proposed by Schouten and coworkers.

2. Computational method and modeling

Calculations were performed in the framework of DFT using the generalized gradient approximation (GGA) of Perdew-Burke-Ernzerhof (PBE)²⁵ and employing ultrasoft pseudopotentials²⁶ for Nuclei and core electrons of all atoms. The calculations of the most stable geometry structure of various adsorption and co-adsorption intermediates were performed using periodic super-cells with the Cu electrodes modeled by four-layer (100) slabs with a 3×3 surface. A vacuum space of 16Å was placed above the slabs and adsorption is allowed on only one of the two surfaces exposed. The Kohn-Sham orbitals were expanded in a plane-wave basis set with a kinetic energy cutoff of 26 Ry and the charge-density cutoff of 260 Ry. The Fermi-surface effects was treated by the smearing technique of Methfessel and Paxton, using a smearing parameter²⁷ of 0.02 Ry. Calculations were carried out with spin-polarization, which is essential to properly represent the

electronic structure of adsorbed various reaction intermediates. The PWSCF codes contained in the Quantum ESPRESSO distribution²⁸ were used to implement all calculations, while figures of the chemical structures were produced with the XCRYSDEN²⁹⁻³¹ graphical package. BZ integrations were performed using a (3×3×1) uniformly shifted k-mesh for (3×3) supercell. The calculated equilibrium lattice constant for Cu was 3.66Å, which agreed well with theoretical and experimental values (3.66 and 3.62Å, respectively).^{32, 33} During the calculations, the structure of the bottom two layers were fixed at the theoretical bulk positions, whereas the top two layers and the adsorbates were allowed to relax and all the other structural parameters were optimized so as to minimize the total energy of the system. Structural optimization was performed until the Cartesian force components acting on each atom were brought below 10⁻³ Ry/Bohr and the total energy converged to within 10⁻⁵ Ry.

The climbing-image nudged elastic band (CI-NEB) method was used to determine the minimum energy paths (MEPs) for all the elementary steps.^{34, 35} The transition state of the optimized reaction coordinate was approximated by the image of highest energy. The transition state images from the CI-NEB calculations were optimized using the quasi-Newton method, which minimizes the forces to find the saddle point. Geometry optimization was performed for each intermediate point in MEPs, in which considering the high cost of CI-NEB calculations, the most stable adsorption configurations of adsorbents obtained on 3×3 surface and a three-layer Cu(100) slab with a 2×3 surface unit cell were used, the bottom two layers of metal atoms were fixed while the top layer of metal atoms and all other nonmetal atoms were allowed to relax.

Fig. 1 Minimum energy path of on Cu(111) CO dissociation and hydrogenation to form C, COH and CHO, respectively. Oxygen atoms are red, hydrogen atoms are white, carbon atoms are gray, and copper atoms are blue.

3. Results

The adsorption, co-adsorption energies and geometry structures of preferred adsorption configurations for various possible reaction intermediates on Cu(100) are given in Tables S1, S2 and Figures S1, S2 in the Supporting Information (SI). The most stable adsorption configurations on Cu(100) are used to perform following MEP analysis. The hydrogenation agent in the elementary reaction steps of reduction mechanism of CO dimer is the adsorbed hydrogen atoms (H*) formed through H₂ dissociation. A Langmuir-Hinshelwood mechanism is involved in reduction mechanism of CO dimer since the adsorbents are co-adsorbed structures on Cu(100). The DFT-calculated activation barrier for H₂ dissociation is 0.45 eV

on Cu(100), which are small and easily to be surmountable. Therefore, the H_2 dissociation should play a relatively minor role in the kinetics of reduction mechanism of CO dimer.

Fig. 2 Minimum energy path of CO dissociation and hydrogenation on Cu(100) to form C, COH and CHO, respectively.

3.1 Selectivity-determining steps of CO reduction on Cu(111) and Cu(100)

The studies conducted by Schouten and coworkers⁸ suggested that there are two separate pathways for the formation of C₂H₄, one that shares an intermediate with the pathway to CH₄, as observed on Cu(111) and below -0.8 V on the Cu(100) surface at pH 7, and a second pathway that occurs only on the Cu(100) surface. Our recent theoretical study 16 had reported the formation pathways of CH₄ and C₂H₄ by the chemical and electrochemical reduction of CO₂ on Cu(111) and Cu(100) that sharing key intermediates CO_{ads}, CHO_{ads}, CH₂O_{ads} and CH₂OH_{ads}. The key intermediate CH_{2ads} can be formed by hydrogenative dissociation of the CH₂OH_{ads} intermediate, finally, the CH₂ intermediate leads to formation of the CH₄ and C₂H₄ by serial hydrogenation and dimerization, respectively. For this second pathway, they suggest that the CO dimer, OCCO* is the key intermediate in the formation of C₂H₄. So far, it is still unclear about selectivity-determining steps, namely, CO hydrogenation or CO dimerization is more favorable on Cu(111) and Cu(100). Therefore, the MEP analysis for CO further reduction is performed in this section to ascertain the selectivity-determining steps. On Cu(111) and Cu(100), there are two possible reactions for the CO further hydrogenation, namely, the hydrogenation to form an adsorbed formyl (CHO*) and hydroxymethylidyne (COH*). Additionally, the direct dissociation to adsorbed C* and O* is also considered. The calculated MEPs (Fig. 1 and 2) suggest that the direct dissociation is particularly energetically demanding, the activation barrier is 3.96 and 3.01 eV on Cu(111) and Cu(100), respectively. The two hydrogenation reactions have relatively lower activation barriers, and the formation of CHO* requires an activation barrier nearly 1.6 eV lower than the formation COH* (~1.0 eV vs ~2.6 eV) on Cu(111). The activation energy barriers for the hydrogenation of CO to form COH* and CHO* required is 2.43 and 2.36 eV on Cu(100), respectively, as shown in Fig. 2. These results indicated that CO hydrogenation requires higher activation energy barriers on Cu(100) than that on Cu(111), which is more easily to achieve on Cu(111). On this basis, it may be able to be concluded that CO further hydrogenation to CHO* is more favorable on Cu(111).

As shown in Fig. 3 and 4, the activation energy barrier for the formation of OCCO* intermediate by CO dimerization on Cu(111) and Cu(100) is 1.59 and 1.26 eV, respectively. Our present results indicated that CO

dimerization into OCCO* intermediate requires higher activation energy barrier than CO hydrogenation into CHO* intermediate on Cu(111), whereas on Cu(100), lower activation energy barrier is required for CO dimerization compared to the formation of CHO* intermediate by CO hydrogenation. Therefore, CO hydrogenation into CHO* during the course of CO further reduction is more easily to occur on Cu(111), whereas CO dimerization into OCCO* is more favorable on Cu(100). A relation between the surface structure of the Cu electrodes and the mechanism of CO reduction is suggested by our present theoretical study, and selectivity-determining steps are revealed on these both different Cu single-crystal electrode surface. The previous experiment study by Hori et al.3, 4, 17-19 on Cu single electrode surfaces and thermodynamic and kinetic theoretical study conducted by Calle-Vallejo et al. and Nørskov et al. 23,36 also showed that on Cu(100) more C₂H₄ is formed whereas on Cu(111) more CH₄ is produced. Therefore, we can speculate that the formation of CH₄ is more favorable on atomically flat (111) parts of the Cu electrode surface through CO hydrogenation into CHO* intermediate, whereas C₂H₄ will be more easily to be formed at (100) sites by CO dimerization. Simultaneously, the previous DFT calculations from Peterson et al. and Nie et al. 11, 14 also suggested that CHO* is the intermediate in the formation of CH₄, and no any experimental evidence indicated that CHO* is the precursor to C₂H₄. ^{8,9} A second key aspect of our present result is that the activation energy barrier for CO dimerization on Cu(100) facet is significantly lower than that on Cu(111) facet. The structure sensitively described by the lowering of the activation energy barrier on Cu(100) relative to Cu(111) implies that Cu(100) facet has more activity for reduction mechanism of CO dimer as indicated in previous experimental studies. Thus, the unique selectivity for the formation of C₂H₄ on (100) can be explained by reduction mechanism of CO dimer (for detailed arguments, see ref 37) and is consistent with the suggestion of Gattrell and coworkers³⁸ who proposed that this CO dimer would be more stable on Cu(100). Additionally, our present results are also in agreement with Schouten and coworkers' experimental study. Currently, the mechanism of C₂H₄ formation initiated by CO dimerization is studied in more detail on Cu(100) for the first time from the point of view of kinetics in our present study as follows.

Fig. 3 Minimum energy paths of CO dimerization into OCCO* intermediate on Cu(111).

Fig. 4 Minimum energy paths of CO dimerization into OCCO* intermediate on Cu(100).

3.2 The Serial Reduction Pathways of CO Dimer into C₂H₄ on Cu(100)

To find intermediates in the reduction of CO dimer, OCCO* into production C₂H₄, we investigated the

reduction of C₂ species. The kinetic energetics of OCCO* intermediate further hydrogenation or dissociation are firstly examined on Cu(100). There are three possibilities for further reduction of OCCO* intermediate. One is dissociation of OCCO* by breaking of C-O bond to form CCO* intermediate; the other two are hydrogenation of OCCO* at C and O atom site to form OCCHO* and OCCOH* intermediates, respectively. In order to compare the degree of difficulty of these two possibilities, the minimum energy path (MEP) analysis was performed. As shown in Fig. 5, the activation barriers for the dissociation of OCCO* into CCO* is 0.91 eV, and further hydrogenation of OCCO* into OCCHO* and OCCOH* on Cu(100) are 0.21 and 1.16 eV, respectively, in which the activation barrier of hydrogenation of OCCO* on C atom site is significantly lower and can be easily overcome at ambient temperature. Although recent theoretical study conducted by Calle-Vallejo and coworkers²³ based on thermodynamics analysis suggested that CCO* is possible reaction intermediate in the electroreduction of CO to C₂ species on Cu(100), the cleavage of C-O bond in OCCO* is unfavorable kinetically on Cu(100). Therefore, it can be concluded that the further reduction of OCCO* into OCCHO* intermediate should be more kinetically favorable on Cu(100).

Fig. 5 Minimum energy paths of OCCO* hydrogenation into OCCHO* and OCCOH*, and dissociation into CCO* by cleavage of C-O bond on Cu(100), respectively.

For further reduction of OCCHO* intermediate, there may be three possibilities on Cu(100). One is hydrogenation of OCCHO* at C atom site into glyoxal (OHCCHO*); the other two is hydrogenation of OCCHO* at O atom site into HOCCHO* and OCCHOH* intermediate, respectively. As shown in Fig. 6, the activation barriers for the further hydrogenation of OCCHO* into OHCCHO*, HOCCHO* and OCCHOH* intermediate on Cu(100) based on the MEP analysis are 0.09, 0.22, and 0.62 eV, respectively, in which the formation of OHCCHO* intermediate requires significantly lower activation energy, and which is almost a non-activated process. Therefore, the hydrogenation of OCCHO* into OHCCHO* intermediate at C atom site is more easily to occur on Cu(100). Our present theoretical calculations are also agreeable with recent experimental study by Schouten and coworkers, in which OHCCHO* intermediate had been observed experimentally as a reaction intermediate during the course of CO reduction on Cu(100).

Fig. 6 Minimum energy paths of OCCHO* intermediate hydrogenation into OCCHOH*, HOCCHO* and OHCCHO* on Cu(100), respectively.

Fig. 7 Minimum energy paths of further reduction of OHCCHO* intermediate into OHCCH₂O*,

OHCCHOH* and OHCCH* on Cu(100), respectively.

Similarity, three possibilities are also considered for further reduction of OHCCHO* intermediate. One is deoxygenation of OHCCHO* intermediate to form adsorbed OHCCH* and O* atom by cleavage of C-O bond; the other two is hydrogenation of OHCCHO* at C and O atom site to form OCHCH₂O* and OHCCHOH* intermediate, respectively. The MEP analysis indicated that the activation barriers for deoxygenation of OHCCHO* into OHCCH* and O* atom is 1.02 eV and the activation barriers for the further hydrogenation of OHCCHO* into OHCCH₂O and OHCCHOH* on Cu(100) are 0.63 and 1.23 eV, respectively, see Fig. 7. The hydrogenation of OHCCHO* at C atom site into OHCCH₂O* has relatively lower activation barrier on Cu(100). Therefore, the formation of OHCCH₂O is the most favorable kinetically reaction pathway on Cu(100) for the further reduction of OHCCHO* intermediate.

Based on above analysis, we can speculate that OHCCHO* and OHCCH₂O* are possible reaction intermediates in reduction mechanism of CO dimer on Cu(100). There are also three possibilities for further reduction of OHCCH₂O*. One is hydrogenation of OHCCH₂O* at C atom site in CHO part into OH₂CCH₂O* intermediate; the other two is hydrogenation of OHCCH₂O* at O atom site in CH₂O and CHO part into OHCCH₂OH* and HOHCCH₂O* intermediate, respectively. For these three possibilities, the MEP analysis was also performed. As shown in Fig. 8, the activation barriers for the further reduction of OHCCH₂O* intermediate into OH₂CCH₂O*, OHCCH₂OH* and HOHCCH₂O* on Cu(100) are 0.38, 0.98 and 0.78 eV, respectively, in which the formation of OH₂CCH₂O* has relatively lower activation barrier on Cu(100). Therefore, it can be predicted that OH₂CCH₂O* should be the most kinetically favorable state derived from the hydrogenation of OHCCH₂O* at C atom site in CHO part on Cu(100).

Fig. 8 Minimum energy paths of further hydrogenation of OHCCH₂O* intermediate into OH₂CCH₂O*, OHCCH₂OH* and HOHCCH₂O* on Cu(100), respectively.

For further reduction of OH₂CCH₂O* intermediate, there may be two possibilities. One is hydrogenation of OH₂CCH₂O* at O atom site into OH₂CCH₂OH* intermediate; another is deoxygenation of OH₂CCH₂O* to form OH₂CCH₂* intermediate by cleavage of C-O bond. The MEP analysis of these two possibilities was performed for comparison. As shown in Fig. 9, the activation barriers for the hydrogenation of OH₂CCH₂O* into OH₂CCH₂OH* intermediate and deoxygenation into OH₂CCH₂* on Cu(100) are 1.21 and 2.71 eV, respectively. By comparing the activation barriers, the formation of OH₂CCH₂OH* has relatively lower barrier, and it is significantly lower than that of the formation of OH₂CCH₂*. Therefore, we can conclude that OH₂CCH₂OH* should be more kinetically favorable intermediate derived from the

hydrogenation of OH₂CCH₂O* intermediate other than OH₂CCH₂* intermediate formed by cleavage of C-O bond in OH₂CCH₂O*.

Fig. 9 Minimum energy paths of further reduction of OH₂CCH₂O* intermediate into OH₂CCH₂OH* by hydrogenation and OH₂CCH₂* on Cu(100) by cleavage of C-O bond, respectively.

Fig. 10 Minimum energy paths of further reduction of OH₂CCH₂OH* intermediate into HOH₂CCH₂OH* by hydrogenation and OH₂CCH₂* by dehydroxylation and H₂CCH₂OH* by deoxygenation on Cu(100), respectively.

Three possibilities are considered for further reduction of OH₂CCH₂OH* intermediate. One is hydrogenation of OH₂CCH₂OH* at O atom site in CH₂O part to form HOH₂CCH₂OH* intermediate; the other two is dehydroxylation and deoxygenation of OH₂CCH₂OH* to form OH₂CCH₂* and H₂CCH₂OH* intermediate, respectively. The MEP analysis for these three possibilities showed that the activation barriers for the further hydrogenation of OH₂CCH₂OH* into HOH₂CCH₂OH*, and dehydroxylation and deoxygenation of OH₂CCH₂OH* to OH₂CCH₂* and H₂CCH₂OH* on Cu(100) are 1.21, 1.36 and 1.12 eV, respectively, see Fig. 10. It can be found that the hydrogenation of OH₂CCH₂OH* into HOH₂CCH₂OH* intermediate and deoxygenation of OH₂CCH₂OH* to H₂CCH₂OH* to H₂CCH₂OH* intermediate have almost identical and relatively lower activation barriers on Cu(100), indicating that these two pathways may be parallel, and may occur simultaneously during the course of C₂H₄ formation.

Fig. 11 Minimum energy paths of further reduction of $HOH_2CCH_2OH^*$ and $H_2CCH_2OH^*$ intermediates into C_2H_4 by dehydroxylation on Cu(100), respectively.

 $HOH_2CCH_2OH^*$ and $H_2CCH_2OH^*$ intermediates may be formed simultaneously on Cu(100) based on above analysis. Therefore, the final product C_2H_4 will be formed possibly by dehydroxylation of $HOH_2CCH_2OH^*$ and $H_2CCH_2OH^*$ intermediates. For these two possibilities, the MEP analysis indicated that the activation barriers for the dehydroxylation of $HOH_2CCH_2OH^*$ and $H_2CCH_2OH^*$ intermediates into C_2H_4 on Cu(100) are 0.45 and 0.28 eV, respectively, as shown in Fig. 11, The results showed that dehydroxylation of $H_2CCH_2OH^*$ into final product C_2H_4 have relatively lower activation barrier on Cu(100), indicating that the reaction may be more easily to occur on Cu(100). However, the activation barriers of the dehydroxylation of $HOH_2CCH_2OH^*$ into production C_2H_4 is also very low, which is also surmountable at ambient temperature. Therefore, these two pathways may occur simultaneously on Cu(100).

Table 1 The optimal reduction pathways for CO dimerization into production C_2H_4 and the activation barriers (E_{act}) of each elementary reaction step on Cu(100).

Reaction Paths	$E_{\rm act}({ m eV})$	
$(CO + CO)^* \rightarrow OCCO^*$	1.26	
$(OCCO + H)^* \rightarrow OCCHO^*$	0.21	
$(OCCHO + H)^* \rightarrow OHCCHO^*$	0.09	
$(OHCCHO + H)^* \rightarrow OHCCH_2O^*$	0.63	
$(OHCCH_2O + H)^* \rightarrow OH_2CCH_2O^*$	0.38	
$(OH_2CCH_2O + H)^* \rightarrow OH_2CCH_2OH^*$	1.21	
$(OH2CCH2OH + H)* \rightarrow HOH2CCH2OH*$	1.21	
$OH_2CCH_2OH^* \rightarrow (H_2CCH_2OH + O)^*$	1.12	
$HOH_2CCH_2OH^* + * \rightarrow H_2CCH_2 + 2OH^*$	0.45	
$H_2CCH_2OH^* \rightarrow H_2CCH_2 + OH^*$	0.28	

4. Discussion

In the present study, a systematic determination of the CO reduction mechanism into production C_2H_4 is presented by CO dimerization on Cu(100), including the selectivity-determining steps, the optimal reduction pathways and rate-determining steps. We present the first DFT study that examines the role of kinetics of elementary reaction steps in reduction mechanism of CO dimer into production C₂H₄ on Cu(100), utilizing the MEP analysis. Based on above results from MEP analysis, the optimal reaction pathways by CO dimerization into production C₂H₄ on Cu(100) can be summarized in Table 1. CO dimer, OCCO* is firstly formed by CO dimerization, and this reaction is more favorable on Cu(100) than the further hydrogenation of CO. Based on the activation barriers, the OH₂CCH₂OH* intermediate either forms HOH₂CCH₂OH* intermediate by direct hydrogenation or forms H₂CCH₂OH* intermediate by cleavage of C-O bond, which maybe parallel pathways in reduction mechanism of CO dimer on Cu(100). Finally, the production C₂H₄ can be formed by dehydroxylation of HOH₂CCH₂OH* and H₂CCH₂OH* intermediates. Based on the calculated activation barriers, the relatively slow steps on Cu(100) include (CO + CO)* \rightarrow OCCO*, (OH₂CCH₂O + H)* \rightarrow OH₂CCH₂OH*, (OH₂CCH₂OH + H)* \rightarrow HOH₂CCH₂OH*, and OH₂CCH₂OH* \rightarrow (H₂CCH₂OH + O)*, in which $(CO + CO)^* \rightarrow OCCO^*$ has the highest activation barrier, and it may be rate-determining step of reduction mechanism of CO dimer into C₂H₄ on Cu(100). Our present mechanistic study explain the experimental observations by Schouten and coworkers that a rate-determining step consist of the coupling of two CO molecules mediated by electron transfer to form OCCO* intermediate on Cu(100). Simutaneously, it can be found that the coupling of C-C bond, hydrogenation at O atom site, and cleavage of C-O bond is more difficult to occur on Cu(100) for CO reduction into production C_2H_4 . The possible reduction mechanism of CO dimer into C_2H_4 is proposed in Fig. 12 based on our DFT calculated results on Cu(100).

Fig. 12 Proposed reduction pathways into production C₂H₄ in reduction mechanism of CO dimer on Cu(100).

In the previous mechanistic study on CO reduction into C₂H₄, the combination of two adsorbed CH₂* species and a CO-insertion type mechanism, namely, a coupling between CH_x and CO leading to the formation of CH_xCO species, were proposed by Hori and coworkers^{3, 4, 17-19, 37} as alternative pathways for the formation of production C₂H₄, but such these two mechanisms cannot explain why main C-C coupling product C₂H₄ is observed experimentally on Cu(100). From thermodynamic view of point, recent theoretical considerations on the reduction of CO by dimerization to production C₂H₄ on Cu(100) electrode were performed by Calle-Vallejo and coworkers, and the possible reduction pathways were proposed. Based on the thermodynamic study, OCCHO* intermediate is less stable than OCCOH* intermediate, suggesting that an initial hydrogenation of the O atom in OCCO* intermediate is a more favorable pathway on Cu(100), and then CCO* intermediate was formed by dehydroxylation of OCCOH* intermediate (i.e. the cleavage of C-O bond). The next favorable step is a hydrogenation of CCO* at C atom site to form HCCO* intermediate, followed by a hydrogenation of HCCO* in the carbonyl group into HCCHO* intermediate. In the next step another hydrogenation takes place at C atom site of HCCHO*, producing H₂CCHO* intermediate. The further reduction pathway of H₂CCHO* proceeds with the hydrogenation of the C atom bonded to the O atom, leading to formation of H₂CCH₂O* intermediate. Finally, the production C₂H₄ was formed by cleavage of C-O bond on Cu(100). Therefore, previous thermodynamic studies showed that CCO*, HCCO*, HCCHO*, H₂CCHO*, and H₂CCH₂O are intermediates of reduction mechanism of CO dimer. However, our present mechanistic studies showed that the initial hydrogenation of OCCO* at C atom site into OCCHO* should be more a favorable pathway on Cu(100) other than forming OCCOH* intermediate by the hydrogenation of O atom, the corresponding activation barriers are 0.21 and 1.16 eV. The OCCHO*, OHCCHO*, OHCCH₂O*, OH₂CCH₂O*, OH₂CCH₂OH*, HOH₂CCH₂OH*, and H₂CCH₂OH* are key reduction intermediates in reduction mechanism of CO dimer on Cu(100), which are not in agreement with the previous thermodynamic study. Furthermore, the formation of HCCHO* is relatively more difficult during the course of further reduction of OHCCHO*, which is not a kinetically favorable pathway, and an activation barrier of 1.02 eV is required by deoxygenation of OHCCHO* (i.e. the cleavage of C-O bond). In our present mechanistic study, H₂CCH₂O* intermediate can be formed by deoxygenation of OH₂CCH₂O* and dehydroxylation of OH₂CCH₂OH*. However, the activation barriers of H₂CCH₂O* formation in these two pathways are very high (2.71 and 1.36 eV, respectively) compared to further hydrogenation of OH₂CCH₂O* and OH₂CCH₂OH*. Therefore, the formation of H₂CCH₂O* intermediate may be not kinetically favorable step during the course of CO reduction by dimerization. Considering the difficulty of cleavage of C-O bond, we can infer that H₂CCHO* is not also reduction intermediate in reduction mechanism of CO dimer. The present mechanistic study results show that the preferred pathway on Cu(100) solely based on reaction free energies may be misleading, and reaction kinetics of elementary reaction steps provide a different mechanistic explanation for selectivity of production C₂H₄ compared to CH₄ on Cu electrodes. An alternative reaction pathway that suggests production C₂H₄ through OCCO* intermediate from CO dimerization is provided in our present mechanistic study. This reduction pathway is consistent with the latest experimental results and explains the puzzle in experiment from Schouten and coworkers.^{8,9} who suggested that OHCCHO*, HOCCOH*, and H₂CCH₂O* are possible reduction intermediates in reduction mechanism of CO dimer into C₂H₄, but still uncertain. Our present research results provide an explanation that OHCCHO* is a key reaction intermediate in reduction mechanism of CO dimer other than HOCCOH* and H₂CCH₂O* on Cu(100). At present, it seems to us that the mechanism proposed in Fig. 12 is most agreeable with the experimental results. In reality, electrode potential should be considered in our present MEP analysis. However, the kinetic model that coupling with electrode potential still need to be further explored in the future because of the uncertainty of the electrode potential, in which the work function differs among these adsorbed states when kinetically modeling electrochemical reaction systems, leading to differences in electrode potentials during the reaction. Although the relationship between the kinetic electrochemical reduction pathways of CO and electrode potential from our present data cannot be deduced, the conclusions in trends are expected to be reasonably accurate.

5. Conclusions

A systematic DFT study that examines the role of kinetics of elementary steps in reduction mechanism of CO dimer into production C_2H_4 on Cu(100) is presented for the first time in the present work, and a new reduction mechanism is introduced. The kinetic analysis of elementary reaction steps have suggested that further reduction of CO is key selectivity-determining step for the formation of production C_2H_4 and CH_4 on Cu(100) and Cu(111). The main reaction pathway on Cu(111) proceeds through reduction of CO into CHO* intermediate, which may eventually result in CH_x species by the breaking of C-O bond, and produce

production CH₄. On Cu(100), CO dimer, OCCO* is firstly formed by CO dimerization, which is the first step and more favorable pathway than the further hydrogenation of CO. It explains why only C₂ species and not C₁ species are observed experimentally on Cu(100). For the formation of production C₂H₄ on Cu(100), the results suggest that hydrogenation of OCCO* to OCCHO* intermediate is the most possible reaction path, followed by the formation of OHCCHO* intermediate through OCCHO* intermediate further hydrogenation. OH₂CCH₂OH* intermediate is formed by serial hydrogenation of OHCCHO*. The OH₂CCH₂OH* intermediate can form HOH₂CCH₂OH* by direct hydrogenation and H₂CCH₂OH* by breaking of C-O bond, which maybe a parallel pathway in reduction mechanism of CO dimer on Cu(100). Finally, the production C₂H₄ is formed by dehydroxylation of HOH₂CCH₂OH* and H₂CCH₂OH* intermediates. The formation of dimer, OCCO* may be rate-determining step in reduction mechanism of CO dimer on Cu(100). In contrast to previous suggested thermodynamic theoretical study on reduction mechanisms of CO dimer into production C₂H₄, our present reaction kinetics of elementary steps give a different mechanistic explanation for selectivity of production C₂H₄. This reduction pathway is consistent with the latest experimental results and explains the puzzle in experiment on uncertainty of reaction intermediates. Our present research results also provide an explanation that OHCCHO* is a key reaction intermediate in reduction mechanism of CO dimer on Cu(100) other than HOCCOH* and H₂CCH₂O* suggested in previous thermodynamic study. At present, it seems to us that the mechanism that proposed in this work is most agreeable with the present experimental results.

Acknowledgements

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A New Reduction Mechanism of CO Dimer by Hydrogenation into C₂H₄ on Cu(100) Surface: A Theoretical Insight into Kinetics of Elementary Steps

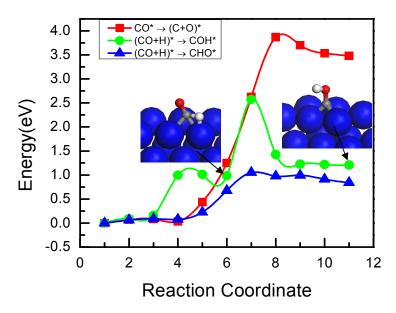


Fig. 1 Minimum energy path of on Cu(111) CO dissociation and hydrogenation to form C, COH and CHO, respectively. Oxygen atoms are red, hydrogen atoms are white, carbon atoms are gray, and copper atoms are blue.

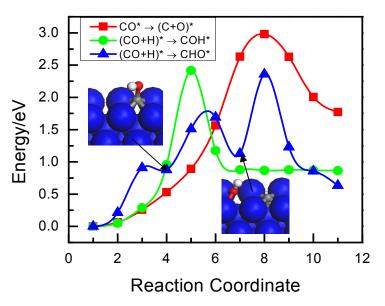


Fig. 2 Minimum energy path of CO dissociation and hydrogenation on Cu(100) to form C, COH and CHO, respectively.

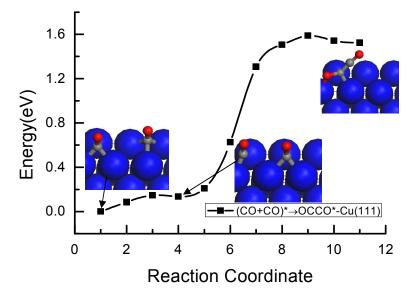


Fig. 3 Minimum energy paths of CO dimerization into OCCO* intermediate on Cu(111).

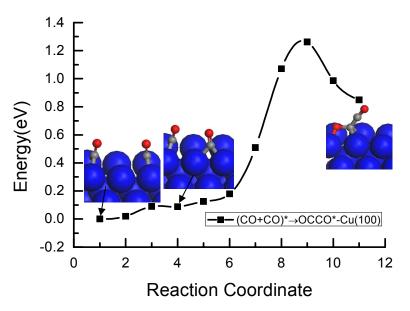


Fig. 4 Minimum energy paths of CO dimerization into OCCO* intermediate on Cu(100).

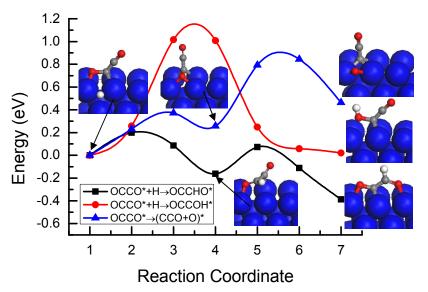


Fig. 5 Minimum energy paths of OCCO* hydrogenation into OCCHO* and OCCOH*, and dissociation into CCO* by cleavage of C-O bond on Cu(100), respectively.

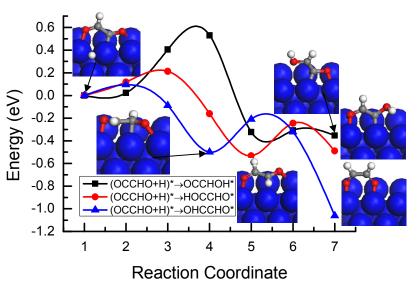


Fig. 6 Minimum energy paths of OCCHO* intermediate hydrogenation into OCCHOH*, HOCCHO* and OHCCHO* on Cu(100), respectively.

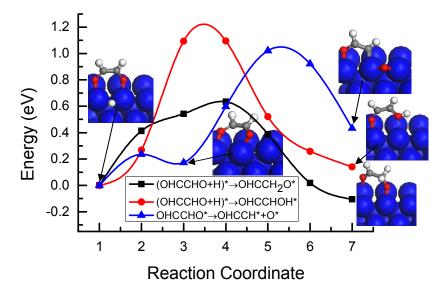


Fig. 7 Minimum energy paths of further reduction of OHCCHO* intermediate into OHCCH₂O*, OHCCHOH* and OHCCH* on Cu(100), respectively.

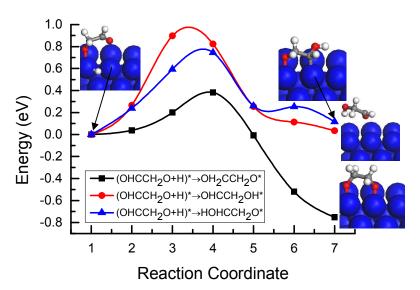


Fig. 8 Minimum energy paths of further hydrogenation of OHCCH₂O* intermediate into OH₂CCH₂O*, OHCCH₂OH* and HOHCCH₂O* on Cu(100), respectively.

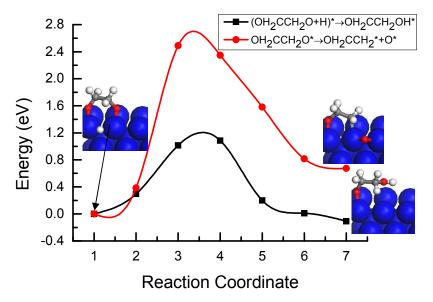


Fig. 9 Minimum energy paths of further reduction of OH₂CCH₂O* intermediate into OH₂CCH₂OH* by hydrogenation and OH₂CCH₂* on Cu(100) by cleavage of C-O bond, respectively.

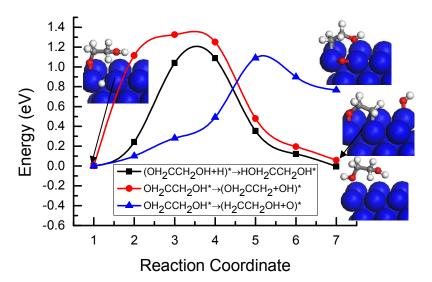


Fig. 10 Minimum energy paths of further reduction of OH₂CCH₂OH* intermediate into HOH₂CCH₂OH* by hydrogenation and OH₂CCH₂* by dehydroxylation and H₂CCH₂OH* by deoxygenation on Cu(100), respectively.

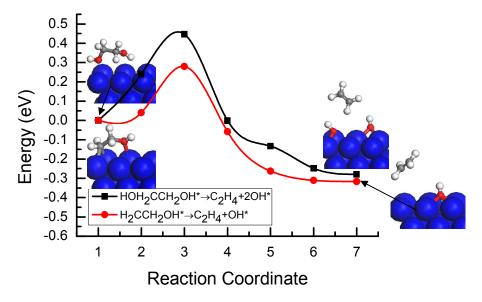


Fig. 11 Minimum energy paths of further reduction of HOH₂CCH₂OH* and H₂CCH₂OH* intermediates into C₂H₄ by dehydroxylation on Cu(100), respectively.

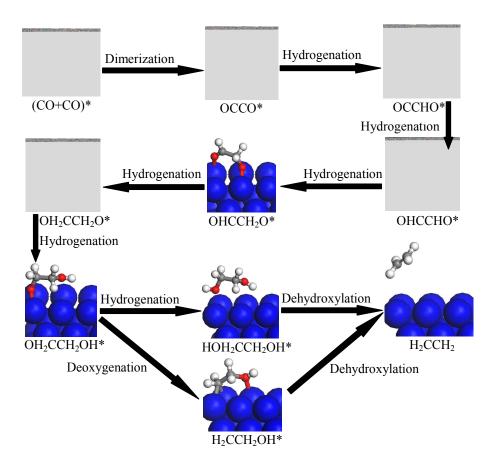


Fig. 12 Proposed reduction pathways into production C₂H₄ in reduction mechanism of CO dimer on Cu(100).